

Abstract

Method and apparatus for producing structures from functional materials, in particular electrical functional materials, in which in a first method step first of all a homogeneous surface tension of the substrate is produced which is higher relative to the normal state of the substrate and then the surface tension of the substrate is reduced in the first or second region to a lower value, the first region being configured in the shape of the structure to be produced. Then in a further method step the functional material is applied to the substrate, the functional material being configured so that it is deposited only in the first region and thus the desired structure is formed from functional material.